

# Air Stable Alucone thin film deposited by Molecular Layer Deposition using Hetero Bifunctional Organic Reactant

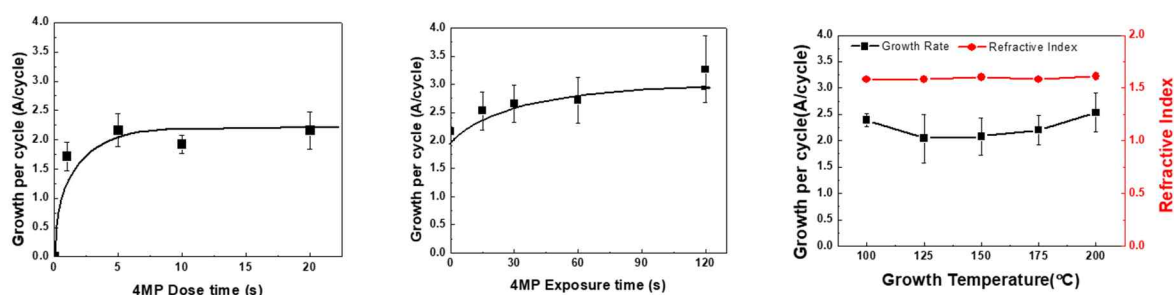
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**Figure 1** Growth of alucone 4MP dose time(left), exposure time(middle), growth temperature(right) dependence